AMENI	DMENT	TRANSMI?	TTAL LETTEI	R (Large	Entity)		Docket No.
Applicant(s): Kathleen L. Covert et al.						EN997064	
Serial No. Filing Date 09/274,935 March 23, 1999			Al	Examiner lexander Marko	off	Group Art Unit	
In and a second	PER CI	LEANING COM	IPOSITIONS, PR	OCESSES.	AND PRODUC	CTS DERIV	VED THEREFROM
FRANCEMENT & TRANCEMENT	7	TO THE /	ASSISTANT COM	MMISSION	ER FOR PATE	NTS:	
Transmitted herev	with is a	n amendment ir	n the above-ident	ified applica	ation.		
The fee has been	ı calcula	ted and is trans	mitted as shown	below.			
			CLAIMS A	AS AMEND	ED		
	CLAIM	IS REMAINING	HIGHEST #	NUM	MBER EXTRA	RATE	ADDITIONAL
OLAINAC		R AMENDMENT	PREV. PAID FOR	-	IMS PRESENT		FEE \$0.00
TOTAL CLAIMS	1	20 - 4 -	20 =			x \$18.	
Multiple Depende			· · · · · · · · · · · · · · · · · · ·		-	^ +	\$0.00
		·	TOTAL ADDITIO	NAL FEE I	FOR THIS AM	ENDMENT	- \$0.00
No additional fee is required for amendment. Please charge Deposit Account No. in the amount of A duplicate copy of this sheet is enclosed. A check in the amount of to cover the filing fee is enclosed. The Commissioner is hereby authorized to charge payment of the following fees associated with this communication or credit any overpayment to Deposit Account No. 09-0457 A duplicate copy of this sheet is enclosed. Any additional filing fees required under 37 C.F.R. 1.16. Any patent application processing fees under 37 CFR 1.17. Dated: 3 210							
cc:					on 3/2 first class ma Assistant Co 20231.	all of an index are a commissione ature of Person	nent and fee is being deposited with the U.S. Postal Service as F.R. 1.8 and is addressed to the for Patents, Washington, D.C. In Mailing Correspondence ark Levy



Disclosure No.

EN896-0258

Patent Attorney

J.R. Pivnichny

Title of Invention (Short & Descriptive)

Method for Microetch Cleaning of Copper Circuits



Functional Manager

CRETEKOS

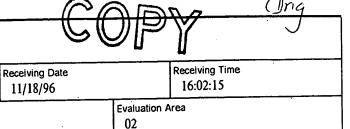
Evaluator

John Pivnichny

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Inve .ion Discl sure EN896-0258

Page 1



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Table 1. Critical Dates Information	10(01)06	
Date invention workable:	10/01/96	
Used or Planned for product:	N	
If so, Product Name?		
Release?		
Announce Date?		
Public Demonstration or Use:	N ·	
If so, When?		·
Where?		
Disclosed to Non-IBMers:	N	
If so, When?		
Where?		
CDA in place?		
Use in Manufacturing:	N	
If so, When?	·	
Where?	•	
Product Name?		



Method for Microetch Cleaning of Co

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Inv nti n Disclosure

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Problem

Conventional microetch cleaning of copper circuits (ie. printed circuit cards and boards) in the presence of nickel / gold, or other precious metal plated contact tabs can lead to complete etch out or near etch out of circuit lines due to the galvanic etch effect associated with common etchants in the presence of precious metals.

An example of this occurs on printed circuit boards having gold plated edge connectors. These gold plated fingers are typically connected by 0.006" wide copper traces to the rest of the circuit board. Prior to shipping the finished circuit board, the board is processed thru an "Entek" process consisting of degreaser, sodium persulfate microetch and Entek to prepare the Cu lands for SMT assembly. Boards have frequently been received from vendors after this "Entek" process, in which the Cu circuit lines connecting the gold tabs have been completely, or nearly completely, etched thru due to galvanic etch effects.

Disclosed here is a sodium persulfate microetchant that is free of galvanic etch effects associated with standard microetch sol-

Entek is a trademark of Enthone OMI.

Solution	· .	37
		马哥州
A copper microetch solution of the following make-up has been defined:		00 P CE
• 25-150 grams/liter sodium persulfate		30 =
 0-5% by volume phosphoric acid 	•	F 720 ET
0-0.25 Molar sodium phosphate dibasic	•	ROO
A preferred formulation of this microstch solvtion is 75, 100	•	3

A preferred formulation of this microetch solution is 75-100 grams per liter of sodium persulfate, 3% by volume phosphoric acid

This etchant is substituted for the standard sodium persulfate microetch chemistry is the standard Entek process flow. Since this formulation is free of galvanic etch effects, circuit boards can be cleaned multiple times without detrimental effects to the copper

Some alternative formulations to the above formulation are as follows:

- · Ammonium, potassium or other persulfates could be substituted for sodium persulfate.
- · Sulfuric acid, or other weak acids could be substituted for phosphoric acid. In the case of sulfuric acid, volume percent should be less than 3%, and preferably less than 1%.
- · Many other phosphate salts could be substituted in place of sodium phosphate dibasic. These could include, by way of example, sodium or potassium phosphates in monobasic, dibasic or tribasic formulations.
- Typical surfactants could be added to the formulation.

Evaluation Questions

If this problem has been solved before, how was it solved?

One previous solution was to insure that the soldermask or protective coating is applied over the interface of the gold plated teb to the copper circuit line. This prevents copper galvanic etching.

Why is your solution better?

This solution does not require a change to the circuit board design. Additionally, when the soldermask is brought closer to the gold plated connector, there is a higher probability of causing a plugging problem, due to flaking or abraded soldermask.